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The new role of surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter in self-promoting syngas conversion to form CH_x intermediates and $C₂$ oxygenates on the Rh-doped Cu catalyst

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ABSTRACT

Syngas conversion to C_2 oxygenates includes two crucial steps that CO activation to form $CH_x(x = 1-3)$ intermediates, followed by its reaction with CO/CHO to form the C--C chain, in which the CH_x($x = 1-3$) intermediates were widely recognized as the reactive intermediates to yield $C₂$ oxygenates. Inspired by the reported studies about the role of co-adsorbed OH intermediates that promote CO activation and the C- C chain formation in syngas conversion, an idea about the new role of surface adsorbed CH_x intermediates in syngas conversion is proposed, that is, whether the surface adsorbed CH_x intermediates itself also act as a co-adsorbed promoter to self-promote CO activation and conversion. This study revealed for the first time that in syngas conversion to C_2 oxygenates over Rh-doped Cu catalysts, the surface adsorbed $CH_x(x = 1-3)$ intermediates not only act as the reactive intermediates to participate into the reactions with CO/CHO, but also itself act as a self-promoter to facilitate CO activation to form $CH_x(x = 1-3)$ intermediates and promote CHO reaction with $CH_x(x = 1-3)$ to form C₂ oxygenates. Especially, the dominant CH2 intermediate acted as a co-adsorbed promoter exhibits higher activity and selectivity towards itself formation and C₂ oxygenates CH₂CHO instead of methanol and hydrocarbons, respectively. Moreover, the internal mechanism of surface adsorbed CH_x intermediate is explained from the electronic property aspect. This newly so-called CH_x self-promoting syngas conversion mechanism offers new insights into the fundamental role of surface adsorbed $CH_x(x = 1-3)$ intermediates in CO activation and conversion to form C_2 oxygenates, and open a new mechanism that is likely general and involved in the reactions related to $CH_x(x = 1-3)$ intermediates formation.

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1. Introduction

Syngas (CO + H_2) conversion to form C_2 oxygenates (typically such as ethanol) is an important process in the transformation of coal, natural gas, and biomass into higher-value products $[1-4]$. At present, the complex reaction network, slow kinetics and low selectivity become the major obstacles for syngas conversion to C_2 oxygenates [\[2\].](#page-10-0) Up to now, there are generally four types of catalysts in syngas conversion to C_2 oxygenates: Rh-based catalyst [\[5–9\],](#page-10-0) Mo-based catalyst [\[10,11\]](#page-11-0), modified F-T synthesis catalyst [\[12–15\]](#page-11-0), and Cu-based catalyst $[16–18]$, in which the catalytic performance of the catalyst is improved by the bimetallic synergetic mechanism. Among them, Rh-doped Cu-based bimetallic catalysts have attracted much attention for CO activation and carboncontaining species hydrogenation in the past years due to the lower cost and the stronger resistance towards coking compared to the Rh-based catalyst [\[19\].](#page-11-0) Experimentally, RhCu alloy catalyst was obtained by a limited miscibility, and the Cu-Rh binary alloy phase diagrams [\[20–23\]](#page-11-0) found that two alloy phases (Rh-rich and Cu-rich) are formed at $T < 1400$ K. Rodriguez et al. [\[24\]](#page-11-0) have investigated Rh deposition on Cu(1 0 0) surface using X-ray Photoelectron Spectroscopy (XPS), and found that Rh centers have a remarkable positive charge. Density functional theory (DFT) studies indicated that the introduction of Cu into Rh or Pd obviously alter CO adsorption ability [\[25,26\].](#page-11-0) Zhao et al. [\[19\]](#page-11-0) discovered that Rh-doped Cu(1 1 1) surface in syngas conversion significantly

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lower the barriers of CO reaction with CH_x and improve the selectivity of C_2 oxygenates in comparison with the Rh(1 1 1) surface. Moreover, Rh-doped Cu(2 1 1) surface facilitates the formation of $CH₃$ and its reaction with CO in comparison with Cu(2 1 1) surface, which exhibits better productivity and selectivity towards ethanol formation [\[27\].](#page-11-0) Thus, in this study, Rh-doped Cu bimetallic catalyst is considered for syngas conversion, in which Cu is considered as the main component, and Rh is used as a second metal.

For the mechanism of syngas conversion to form C_2 oxygenates, two crucial steps are generally accepted: one is that CO activation to form key $CH_x(x = 1-3)$ intermediates via the CO direct or Hassisted dissociation mechanism [\[28\]](#page-11-0), CO is directly dissociated into C, then, C is successively hydrogenated to produce CH_x($x = 1-3$) intermediates [\[27\]](#page-11-0); alternatively, H-assisted CO dissociation goes through CO hydrogenation to $CH_xO(x = 1-3)$ or CH_xOH $(x = 1,2)$, then, the dissociation of CH_xO($x = 1-3$) or CH_xOH($x = 1,2$) via the C-O bond breakage to form $CH_x(x = 1-3)$ intermediates; moreover, CH_xO or CH_xOH can also be hydrogenated to form methanol. The second step is CO/CHO reaction with $CH_x(x = 1-3)$ intermediates to produce the C-C bond of C_2 oxygenates [\[5,19,29–32\],](#page-10-0) in which CH_x intermediate as an important species go through the successive hydrogenation, CO/CHO reaction with CH_x or the coupling of CH_x leading to the formation of methane, C_2 oxygenates or C_2 hydrocarbons, respectively [\[5,19,27,30–36\].](#page-10-0)

On the basis of above analysis, it is concluded that $CH_x(x = 1-3)$ species acted as the key intermediate can yield C_2 oxygenates. However, along with the formation of $CH_x(x = 1-3)$ over the Rh-, Co- and Cu-based catalysts [\[5,19,27,30–38\]](#page-10-0), which mainly come from the dissociation of $CH_xO(x = 1-3)$ or $CH_xOH(x = 1,2)$ by its C –O bond breakage, the intermediates such as O and OH species are also produced. Since syngas conversion is carried out under the hydrogen-rich conditions, the produced O or OH species will be hydrogenated to form OH or H_2O . Up to now, extensive studies have investigated the roles of $H₂O$ and OH species in syngas conversion [\[39–48\].](#page-11-0) Jiménez-Barrera et al. [\[44\]](#page-11-0) demonstrated that low concentration of $H₂O$ contributes to CO dissociation on Ru/Al_2O_3 catalyst; Storsæter et al. [\[45\]](#page-11-0) reported the effect of H₂O on the alumina supported cobalt catalysts, where H_2O irreversibly deactivates the catalyst in the Fischer–Tropsch synthesis. Similarly, the surface OH species is also of great importance for syngas conversion, Schweicher et al. [\[46\]](#page-11-0) experimentally investigated syngas conversion over Co/MgO catalyst, and confirmed the existence of surface OH species contributes to the formation of carbon chain; Gunasooriya et al. [\[47\]](#page-11-0) found that CO activation to form the CH species and the carbon chain on $Co(1 1 1)$ surface under the surface OH-assisted is more preferred over that under the surface H-assisted; Zha et al. [\[48\]](#page-11-0) compared CO activation over Co-doped Cu(1 1 1) surface under the H- and OH-assisted conditions, indicating that the OH-assisted promotes CO hydrogenation to CH_xOH $(x = 1,2)$, followed by its dissociation via the C-O bond cleavage leading to CH_x species.

Based on above analysis, especially inspired by the role of OH species in syngas conversion that promotes CO activation to form the CH_x($x = 1-3$) intermediates and facilitates the C-C bond formation, an idea about the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates in syngas conversion is proposed, except for the well-known role of $CH_x(x = 1-3)$ intermediates acted as the reactive species to participate into the reaction with CO/CHO, more importantly, whether the surface adsorbed $CH_x(x = 1-3)$ intermediates can act as a co-adsorbed promoter to self-promote syngas conversion, including CO activation to form $CH_x(x = 1-3)$ species and CO/CHO reaction with CH_x(x = 1–3) to form C₂ oxygenates. Hereafter, we call this new mechanism as CH_x self-promoting syngas conversion mechanism.

In this study, aiming at revealing the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates acted as a co-adsorbed promoter in self-promoting syngas conversion to form C_2 oxygenates, Rh-doped Cu catalysts with four kinds of model surfaces were built to reflect the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter; then, CO activation to form $CH_x(x = 1-3)$ species and the related reaction of $CH_x(x = 1-3)$ species leading to methane, the C-C bond formation of C_2 oxygenates and hydrocarbons are fully examined using the density functional theory (DFT) calculations. Further, the electronic properties including the Bader charge, the differential charge density, density of states, and the d-band center were systematically analyzed, which presents the correlation between the electronic property and catalytic performance affected by the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates.

2. Computational details

2.1. Calculation methods

The Vienna Ab-initio Simulation Package (VASP) code was used to perform all DFT calculations in this study [\[49,50\]](#page-11-0). We adopt the generalized gradient approximation (GGA) with the exchangecorrelation functional Perdew-Burke-Ernzerhof (PBE) [\[51\].](#page-11-0) The optimization convergence of three-layers RhCu(1 1 1) surface was checked with the forces less than 0.01 eV \AA^{-1} and the energy difference less than 5×10^{-6} eV, which is also applied in the geometry optimization. On the other hand, the climbing-image nudged elastic band method (CI-NEB) was employed to obtain the transi-tion states for each elementary reaction [\[52,53\]](#page-11-0). The dimer method [\[54,55\]](#page-11-0) was carried out to further optimize the transition states with the convergence criteria of the force acting on the atom less than 0.05 eV Å; then, the energy of the transition state structure is further calculated at the convergence force criteria of 0.01 eV \AA^{-1} . Thus, the calculated energies in this study are all at the convergence force criteria of $0.01 \text{ eV} \cdot \text{\AA}^{-1}$, which can be well compared among these energy values; meanwhile, the transition state was verified using the single imaginary frequency. Supplementary Material lists the details for calculating relevant energy.

2.2. Surface model

Based on the experiment and theoretical studies [\[19–27\],](#page-11-0) Rh-doped Cu catalysts is modeled using Rh-doped Cu(1 1 1) surface. For the Rh-doped Cu(1 1 1) surface, as shown in [Fig. 1](#page-2-0)(a), a $p(3 \times 3)$ three-layer supercell Cu(1 1 1) surface was employed with a vacuum slab of 15 Å; then, one surface Cu atom is replaced by one Rh atom, denoted as RhCu(1 1 1). During the calculations, the bottom one layer was fixed to model the bulk positions, while other layers and the adsorbates are allowed to relax. In addition, the three-layer model employed in this study has been widely applied to the reactions of ethanol oxidation, decomposition, synthesis, and methanol formation [\[56–59\]](#page-11-0). In addition, in order to further verify the rationality of three-layers Rh/Cu(1 1 1) surface model, the adsorption energies of CO at the top Rh site as the most stable site over the four- and five-layers Rh/Cu(1 1 1) surface models (the bottom one layers are fixed to their bulk positions, and the other top layers and with adsorbates are relaxed) are further calculated. The corresponding adsorption energies of CO are 182.9 and 185.8 kJ·mol⁻¹ over the four- and five-layers RhCu(1 1 1) surfaces, respectively, which are close to the value of 183.9 kJ \cdot mol $^{-1}$ over the three-layer RhCu(1 1 1) surface, suggesting that the threelayers RhCu(1 1 1) surface employed in this study is reasonable and reliable to investigate syngas conversion to C_2 oxygenates.

There are four types of adsorption sites (top, bridge, fcc and hcp) over the RhCu(1 1 1) surface, which correspond to nine different sites due to the adsorption site consisted of different types of metal

Fig. 1. The surface morphology and adsorption sites of RhCu(1 1 1) and CH_x(x = 1-3)/RhCu(1 1 1) surfaces. Orange, dark green, green and yellow balls correspond to Cu, Rh, C and H atoms, respectively.

atoms, as shown in Fig. 1(a), top, top-1, bridge, bridge-1, bridge-2, fcc, fcc-1, hcp, and hcp-1, respectively.

On the other hand, aiming at identifying the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter over Rh-doped Cu catalysts, as shown in Fig. $1(b)$ –(d), three types of RhCu(1 1 1) surfaces are constructed using the CH, CH₂ or CH₃ intermediates adsorbed on the clean RhCu(1 1 1) surface, which are named as $CH/RhCu(1 1 1)$, $CH₂/RhCu(1 1 1)$ and $CH₃/RhCu$ (1 1 1) surfaces, respectively.

3. Results and discussions

3.1. CO activation to form $CH_x(x = 1-3)$ intermediates

As mentioned in Introduction, the formation of $CH_x(x = 1-3)$ intermediates via CO direct dissociation hardly occur on the Cu [\[27,37,38\],](#page-11-0) Rh [30,35,60-62] and Rh-doped Cu(111) surfaces [\[27\]](#page-11-0), which mainly comes from H-assisted CO dissociation mechanism. Subsequently, CO/CHO reaction with the dominant CH_x(x = 1-3) monomer leads to C_2 oxygenates. As a result, the formation of $CH_x(x = 1-3)$ intermediates via the mechanism of H-assisted CO dissociation on Rh-doped Cu catalyst is investigated in this study. All possible elementary reactions involving in the formation of CH_x($x = 1-3$) intermediates, methane, as well as the C-C bond formation of C_2 oxygenates and hydrocarbons on the RhCu (1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces are listed in Table 1. The energy profile of the optimal formation route of $CH_x(x = 1-3)$ and $CH₃OH$ are shown in Figs. 3-5 (see details in Figs. S2-S7).

3.1.1. The adsorption and co-adsorption of key intermediates

The adsorption energy can be used to evaluate the strength between the adsorbates and the catalyst, which plays a crucial role

Table 1

Activation free energy (ΔG _a) and reaction free energy (ΔG) of the elementary reactions involving in the formation of C₂ oxygenates from syngas over the RhCu(1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces at 523 K.

Reactions		$\Delta G_a(\Delta G)/k$ [·mol ⁻¹			
		RhCu(111)	CH/RhCu(111)	CH ₂ /RhCu(111)	CH ₃ /RhCu(111)
$Rx-1$	$CO + H \rightarrow CHO$	112.9(103.8)	90.3(63.8)	106.1(88.2)	108.7(84.4)
$Rx-2$	$CHO \rightarrow CH + O$	213.8(136.5)	231.5(137.2)	174.2(129.9)	152.9(114.3)
$Rx-3$	$CHO + H \rightarrow CHOH$	84.2(12.2)	72.4(28.4)	80.7(42.0)	80.1(37.9)
$Rx-4$	$CHOH \rightarrow CH + OH$	155.3(65.0)	117.6(68.6)	115.6(41.5)	106.1(22.3)
$Rx-5$	$CHO + H \rightarrow CH2O$	44.9(20.4)	48.6(27.3)	50.8(33.7)	49.6(15.2)
$Rx-6$	$CH2O \rightarrow CH2 + O$	170.7(84.9)	178.8(68.2)	140.1(67.6)	198.0(113.1)
$Rx-7$	$CH2O + H \rightarrow CH2OH$	100.6(20.4)	$75.3(-2.4)$	$80.6(-1.3)$	85.7(18.4)
$Rx-8$	$CHOH + H \rightarrow CH2OH$	$38.9(-2.0)$	$38.1(-28.2)$	$40.6(-15.1)$	$85.7(-1.1)$
$Rx-9$	$CH2OH \rightarrow CH2 + OH$	110.6(31.0)	107.6(37.1)	55.1(21.7)	$77.9(-1.5)$
$Rx-10$	$CH2O + H \rightarrow CH3O$	53.6(9.2)	$58.8(-17.7)$	$60.8(-22.8)$	$59.8(-40.2)$
$Rx-11$	$CH3O \rightarrow CH3 + O$	141.9(46.0)	163.5(47.4)	174.1(71.6)	167.3(65.6)
$Rx-12$	$CH_3O + H \rightarrow CH_3OH$	100.2(0.4)	$57.2(-8.3)$	69.6(5.6)	$51.2(-14.2)$
$Rx-13$	$CH2OH + H \rightarrow CH3OH$	$33.0(-40.6)$	$40.0(-34.0)$	$32.1(-53.2)$	$37.9(-71.6)$
$Rx-14$	$CH2 \rightarrow CH + H$	50.2(0.1)	85.5(54.8)	$84.5(-57.1)$	81.4(42.6)
$Rx-15$	$CH2 + H \rightarrow CH3$	$35.4(-39.8)$	$45.1(-60.3)$	$46.0(-48.0)$	$48.2(-40.6)$
$Rx-16$	$CH_3 + H \rightarrow CH_4$	$28.6(-52.3)$	$26.8(-80.4)$	$26.4(-87.5)$	$16.1(-97.5)$
$Rx-17$	$CH2 + CH2 \rightarrow C2H4$	$43.5(-165.6)$	$70.4(-138.3)$	$75.6(-125.3)$	$36.0(-156.3)$
$Rx-18$	$CO + CH2 \rightarrow CH2CO$	51.8(4.5)	61.0(4.1)	80.8(23.1)	$48.9(-8.9)$
$Rx-19$	$CHO + CH2 \rightarrow CH2CHO$	$31.9(-84.3)$	$37.6(-72.2)$	$24.4(-83.2)$	$5.6(-108.4)$

It is noted that the values of x is 1–4 corresponding to the RhCu(1 1 1) and CHx(x = 1–3)/RhCu(1 1 1) surfaces, respectively.

Fig. 2. The adsorption energy of key CO, CHO, CHOH, CH₂OH and CH₃O intermediates in the form of the single adsorption, as well as in the presence of surface adsorbed H, CH, $CH₂$ and CH₃ intermediate, respectively.

in the catalytic reaction. Up to now, most of the studies only investigate the single adsorption of key intermediates (CO, CHO, $CH₂O$, $CH₃O$, CHOH, CH₂OH) in syngas conversion and their coadsorption with the H, O or OH species [\[30,48,63,64\].](#page-11-0) In this study, to gain a better understanding about the new role of surface adsorbed $CH_x(x = 1-3)$ intermediate as a co-adsorbed promoter, the adsorption behaviors of these key intermediates are examined on the RhCu(1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces (see details in Fig. S1 and Table S1). The results show that all C_1 species (CO, CHO, CH₂O, CH₃O, CHOH, CH₂OH and CH₃OH) prefer to be located at the top Rh site, Rh-Cu bridge site and the fcc site consisted of a Rh atom and two Cu atoms.

As presented in Fig. 2, compared to the adsorption of single $CH_xO(x = 0-3)$ and $CH_xOH(x = 1,2)$ intermediates, the co-adsorbed H or $CH_x(x = 1-3)$ species decrease the adsorption energy of key intermediates $CH_xO(x = 0-3)$ and $CH_xOH(x = 1,2)$, suggesting that the presence of H or CH_x($x = 1-3$) species is favorable for the migration of these key intermediates on RhCu(1 1 1) surface. Moreover, compared to H species, $CH_x(x = 1-3)$ species is more favorable to decrease the adsorption energies of $CH_xO(x = 0-3)$ and CH_xOH $(x = 1,2)$ intermediates, the lateral interactions induced by the presence of $CH_x(x = 1-3)$ species change the adsorption sites of CH_xOH($x = 1,2$) and CH_xO($x = 0-3$) intermediates, which is similar to that the lower adsorption energy favored the migration of adsorbates among the active sites of catalyst surface [\[48,64\].](#page-11-0)

3.1.2. CH formation

In the H-assisted CO dissociation mechanism, CH is produced via the dissociation of CHO or CHOH intermediates via the $C-O$ bond breakage. On the clean RhCu(1 1 1) and $CH_x(x = 1-3)/R$ hCu (1 1 1) surfaces, as presented in [Fig. 3,](#page-4-0) CH formation dominantly goes through the route of $CO + 2H \rightarrow CHO + H \rightarrow CHOH \rightarrow CH$ + OH, which have the overall barriers of 271.3, 210.5, 246.7 and 228.4 kJ·mol⁻¹, respectively; they are all endothermic by 181.0, 161.5, 172.6 and 144.6 kJ mol⁻¹, respectively. Thus, $CH_x(x = 1-3)$ / RhCu(1 1 1) surface is more advantageous to CH formation in kinetics and thermodynamics than the clean RhCu(1 1 1) surface, suggesting that surface adsorbed $CH_x(x = 1-3)$ intermediates acted as the co-adsorbed promoter over RhCu(1 1 1) surface not only promotes syngas conversion to form CH intermediate, but also exhibits different promotion effect towards CH formation with the activity order of $CH/RhCu(1\ 1\ 1)$ > $CH_3/RhCu(1\ 1\ 1)$ > $CH_2/$ $RhCu(1 1 1)$ > $RhCu(1 1 1)$.

3.1.3. $CH₂$ formation

 $CH₂$ can be produced by the dissociation of CH₂O or CH₂OH intermediates via the $C=0$ bond cleavage. On the RhCu(111) and $CH_x(x = 1,2)/RhCu(1 1 1)$ surfaces (see [Fig. 4\(](#page-5-0)a)–(c)), the route of CO + H \rightarrow CHO + H \rightarrow CHOH + H \rightarrow CH₂OH \rightarrow CH₂ + OH is mainly responsible for $CH₂$ formation, which are endothermic by 145.0, 101.5 and 119.1 kJ \cdot mol⁻¹ with the overall barriers of 224.6, 172.0 and 174.8 kJ·mol⁻¹, respectively. Interestingly, on $CH₃/RhCu$ $(1 1 1)$ surface, as presented in [Fig. 4](#page-5-0)(d), the main route is $CO + 3H \rightarrow CHO + 2H \rightarrow CH_2O + H \rightarrow CH_2OH \rightarrow CH_2 + OH$, this route is also endothermic by 116.5 kJ·mol⁻¹ with the overall barrier of 195.9 kJ \cdot mol $^{-1}$.

As mentioned above, in comparison with the clean RhCu(1 1 1) surface, $CH_x(x = 1-3)/RhCu(1 1 1)$ surface prefers to form CH_2 in kinetics and thermodynamics, namely, the surface adsorbed $CH_x(x = 1-3)$ intermediates acted as the co-adsorbed promoter also facilitates $CH₂$ formation, moreover, it change the optimal route of CH₂ formation, the activity order is CH/RhCu(1 1 1) \approx CH₂/RhCu $(1 1 1)$ > CH₃/RhCu(1 1 1) > RhCu(1 1 1).

3.1.4. $CH₃$ and methanol formation

CH₃ formation has only one route of CO + 3H \rightarrow CHO + 2H \rightarrow $CH_2O + H \rightarrow CH_3O \rightarrow CH_3 + O.$ On the RhCu(111) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces, as shown in [Fig. 5](#page-6-0), this route has the overall barriers of 275.3, 236.9, 273.2 and 226.7 kJ·mol⁻¹, which need to be endothermic by 179.4, 121.0, 170.7 and 125.0 kJ·mol⁻¹, respectively. Thus, the activity order of $CH₃$ formation is $CH_3/RhCu(1 1 1)$ > $CH/RhCu(1 1 1)$ > $CH_2/RhCu(1 1 1)$ \approx RhCu (1 1 1).

Methanol is generated by $CH₃O$ or $CH₂OH$ hydrogenation, which affects the productivity of $CH_x(x = 1-3)$ intermediates and C_2 oxygenates. As displayed in Fig. $5(a)-(c)$, on the RhCu(111), CH/ RhCu(111) and $CH₂/RhCu(111)$ surfaces, the route of CO $+ 4H \rightarrow CHO + 3H \rightarrow CHOH + 2H \rightarrow CH₂OH + H \rightarrow CH₃OH$ dominantly contribute to methanol formation, this route has the overall barriers of 188.0, 136.2 and 174.8 k J·mol⁻¹, which need to be endothermic by 116.0, 92.2 and 119.1 $\text{kJ} \cdot \text{mol}^{-1}$, respectively. However, on $CH_3/RhCu(1 1 1)$ surface (see [Fig. 5](#page-6-0)(d)), $CO + 4H \rightarrow CHO$ $+ 3H \rightarrow CH_2O + 2H \rightarrow CH_3O + H \rightarrow CH_3OH$ is the main route of methanol formation, which has the overall barrier of 159.4 kJ·mol⁻¹, and it needs to be endothermic by 59.4 kJ·mol⁻¹. Thus, the catalytic activity order of methanol formation is $CH/RhCu(1 1 1)$ > $CH_3/RhCu(1 1 1)$ > $CH_2/RhCu(1 1 1)$ > $RhCu(1 1 1)$.

Based on above results, it is concluded that in comparison with the clean RhCu(1 1 1) surface, the surface adsorbed $CH_x(x = 1-3)$ intermediate acted as a co-adsorbed promoter not only promote the formation of $CH₃$ and methanol, but also alter the optimal route of methanol formation. Moreover, compared to $CH₃$ formation, methanol formation is more preferred in kinetics, which agree with the previous studies on the Cu-based or Rh-based catalysts [\[27,30,37,62,65\].](#page-11-0)

3.1.5. The most favored CH_x monomer

Fig. $6(a)$ shows the overall barrier of the optimal CH, CH₂ and $CH₃$ formation route. On RhCu(1 1 1) surface, CH, CH₂ and CH₃ formation correspond to the overall barriers of 271.3, 224.6 and 275.3 kJ·mol⁻¹, respectively, indicating that the dominant CH_x monomer is $CH₂$ intermediate due to the lowest overall barrier of 224.6 kJ mol⁻¹, our results are consistent with the reported results over RhCu(1 1 1) surface [\[11\].](#page-11-0) Similarly, on $CH_x(x = 1-3)/R$ hCu (1 1 1) surface, the dominant CH_x monomer is also CH_2 intermediate. Namely, the dominant CH_x monomer is CH₂ over RhCu(1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces. More importantly, $CH_x(x = 1-3)/RhCu(1 1 1)$ surface is more preferred for CH₂ formation in kinetics than the clean RhCu(1 1 1) surface. In addition, previous studies about syngas conversion also found that the dominant

Fig. 3. The potential energy profiles for the most favorable route of CH formation with the transition states on the (a) RhCu(1 1 1), (b) CH/RhCu(1 1 1), (c) CH/RhCu(1 1 1), and (d) CH₃/RhCu(111). Orange, dark green, red balls represent Cu, Rh, O atoms, respectively. Gray and while balls are C and H atoms involving in the reaction, green and yellow balls are the C and H atoms of co-adsorbed promoter CH_x species that cannot participate into the reaction.

 CH_x monomer is $CH₂$ intermediate on the Rh-based, Cu-based, and Co-based catalysts [\[34,35,37,65–69\]](#page-11-0), for example, the isotope tracer by Jackson et al. $[69]$ found that CH₂ is the key intermediate on Rh catalyst. Among all $CH_x(x = 1-3)$ intermediates, Kapur et al. [\[35\]](#page-11-0) theoretically proposed that $CH₂$ is the dominant monomer over the (1 1 1) and (2 1 1) surfaces of Rh catalyst, which is also supported over the Co(10-11) [\[67\],](#page-11-0) Cu(111) [\[65\],](#page-11-0) Cu(110) [\[37\]](#page-11-0) and Fe-modified Cu(2 1 1) surfaces $[34]$. Meanwhile, as shown in [Fig. 4,](#page-5-0) the optimal formation route of the dominant $CH₂$ monomer is different over four types of RhCu(1 1 1) surfaces.

Above results show that the presence of surface adsorbed $CH_x(x = 1-3)$ intermediate as a co-adsorbed promoter not only promote the formation of the dominant $CH₂$ monomer, but also change the optimal formation route of $CH₂$. More importantly, $CH₂$ intermediate itself as the dominant $CH_x(x = 1-3)$ monomer should be the dominant co-adsorbed promoter over RhCu(1 1 1) surface in syngas conversion.

3.2. The carbon chain formation of C_2 oxygenates

Previous studies show that when $CH_x(x = 1-3)$ monomer is produced, four types of reactions related to $CH_x(x = 1-3)$ may occur [\[5,19,27,30–34\]:](#page-10-0) CH_x hydrogenation to methane, CH_x dissociation, CH_x reaction with CO/CHO to produce $C₂$ oxygenates, and CH_x coupling leading to C_2 hydrocarbons. The formation of hydrocarbons species $(C_2$ hydrocarbons and methane) decreases the selectivity of C_2 oxygenates [\[32,70,71\]](#page-11-0). Based on the dominant monomer CH₂ over the RhCu(1 1 1) and CH_x($x = 1-3$)/RhCu(1 1 1) surfaces, in this study, all related reactions of $CH₂$ monomer, $CH₂$ dissociation to form CH, $CH₂$ successive hydrogenation to methane, $CH₂$

Fig. 4. The potential energy profiles for the most favorable route of CH₂ formation together with the transition states on (a) RhCu(111), (b) CH/RhCu(111), (c) CH₂/RhCu $(1 1 1)$ and (d) CH₃/RhCu $(1 1 1)$ surfaces.

self-coupling and CO/CHO reaction with $CH₂$ are examined, as listed in [Table 1](#page-2-0) (details in Fig. S8).

[Fig. 7](#page-7-0) presents the overall barrier of all reactions related to $CH₂$ monomer on the four surfaces. On RhCu(1 1 1), the formations of C_2 oxygenates and CH₄ is energetically competitive (31.9 vs. 35.4 kJ mol⁻¹). However, on CH/RhCu(1 1 1), CH₂/RhCu(1 1 1) and $CH₃/RhCu(1 1 1)$ surfaces, CHO reaction with CH₂ leading to C₂ oxygenates prefers to occur, which have the corresponding overall barriers of 34.6, 24.4 and 5.6 kJ mol $^{-1}$, respectively; whereas the corresponding by-product mainly focus on the hydrocarbons CH4, $CH₄$ and $C₂H₄$ corresponding to the overall barriers of 45.1, 46.0 and 36.0 kJ·mol⁻¹, respectively. Thus, $CH_x(x = 1-3)/RhCu(1\ 1\ 1)$ exhibits better selectivity towards the formation of C_2 oxygenates compared to the clean RhCu(1 1 1) surface, indicating that the surface adsorbed $CH_x(x = 1-3)$ intermediate acted as a co-adsorbed promoter over RhCu(1 1 1) surface promotes the formation of C_2 oxygenates in syngas conversion.

In addition, since the reactions related to CH_x species over the p (3×3) CH_x(x = 1–3)/RhCu(1 1 1) surfaces employed in this study have three species, the lateral interaction may affect the barrier for the reactions related to CH_x species. Meanwhile, our results show that $CH₂/RhCu(1 1 1)$ surface significantly promote $CH₂$ formation compared to RhCu(111), CH/RhCu(111) and CH₃/RhCu $(1 1 1)$ surfaces. As a result, the reactions related to CH₂ species over the $p(4 \times 4)$ CH₂/RhCu(1 1 1) surface are considered, moreover, the formation of $CH₂CHO$ and major by-products (CH₄ and C_2H_4) over the $p(4 \times 4)$ CH_x(x = 1,3)/RhCu(1 1 1) surfaces are also examined (see details in the Part 5 of Supplementary Material). Our results show that the supercell size of $CH_x(x = 1-3)/RhCu$ (1 1 1) surface can affect the values of the reaction barrier to a

Fig. 5. The potential energy profiles for the most favorable route of CH₃ formation together with the transition states on (a) RhCu(111), (b) CH/RhCu(111), (c) CH₂/RhCu $(1 1 1)$ and (d) CH₃/RhCu $(1 1 1)$ surfaces.

small extent, however, C_2 oxygenates CH₂CHO is still the main product over the $p(4 \times 4)$ CH_x(x = 1–3)/RhCu(1 1 1) surfaces, suggesting that the results obtained over the $p(4 \times 4)$ CH_x(x = 1–3)/RhCu (1 1 1) surfaces agree with that obtained over the $p(3 \times 3)$
CH_x(x = 1-3)/RhCu(1 1 1) surfaces, namely, the $p(3 \times 3)$ $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces,

 $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces employed in this study can well qualitatively reflect the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter in self-promoting syngas conversion to form CH_x intermediates and C_2 oxygenates on the Rh-doped Cu catalyst.

Fig. 6. (a) The overall barrier for the most favorable formation routes of $CH_x(x = 1 -$ 3) and CH₃OH with respect to CO + H species, (b) the reaction rates of CH_x($x = 1-3$) formation over the RhCu(1 1 1) and CH_x($x = 1-3$)/RhCu(1 1 1) surfaces at 523 K.

Fig. 7. The overall barriers for the reactions related to $CH₂$ species on RhCu(111) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces at 523 K.

3.3. General discussions

3.3.1. The role of adsorbed CH_x($x = 1-3$) intermediates in the CH_x formation

Based on the above analysis, as shown in Fig. $6(a)$, the overall formation barrier of CH_x($x = 1-3$) intermediates over RhCu(1 1 1) surface is higher than that over $CH_x(x = 1-3)/RhCu(1 1 1)$ surface, indicating that the surface adsorbed $CH_x(x = 1-3)$ intermediate acted as a co-adsorbed promoter in syngas conversion over RhCu (1 1 1) surface enhances the catalytic activity of $CH_x(x = 1-3)$ itself formation. Especially, for the dominant $CH₂$ monomer, the activity order of CH₂ formation is CH/RhCu(1 1 1) \approx CH₂/RhCu(1 1 1) $>$ CH₃/ $RhCu(1 1 1)$ > $RhCu(1 1 1)$. Further, taking the coverage of surface intermediates in the process of CO activation to form CH_x intermediates into consideration, the reaction rates of CO activation to form CH_x species based on a microkinetic modeling using the data presented in [Table 1](#page-2-0) (see details in the Part 7 of Supplementary Material) are calculated, the microkinetic model [\[30,67,72,73\]](#page-11-0) has been widely applied in CO activation to form CH_x species with

the aim of estimating the reaction rate of $CH_x(x = 1-3)$ under the typical experimental conditions $(P_{CO} = 4 \text{ atm}, P_{H2} = 8 \text{ atm};$ $T = 523$ K). As shown in Fig. $6(b)$, the results obtained by Microkinetic modeling show that the formation rate for CO activation to form $CH₂$ intermediate is much higher than those of CH and $CH₃$ intermediates over the $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces, as well as those of $CH_x(x = 1-3)$ intermediates over the pure RhCu(1 1 1) surface; as a result, compared to the pure RhCu(111) surface, the surface adsorbed $CH_x(x = 1-3)$ species acted as a co-adsorbed promoter over RhCu(1 1 1) surface exhibit the highest catalytic activity toward CO activation to form the dominant monomer CH₂ among all CH_x($x = 1-3$) intermediates, which agree with our above results obtained by DFT calculations (the activation barrier), as shown in Fig. 6(a). However, it is noted that our DFT results suggest that CH₂ monomer is preferentially formed on the pure RhCu (1 1 1) surface, which is not in agreement with the microkinetic modeling that CH_3 monomer is preferentially formed; this phenomenon can be attributed to the formation rate of products not only rely on the rate constant (determined by the activation barrier), but also depend on the coverage of key intermediates involving CO activation to form $CH_x(x = 1-3)$.

On the other hand, in syngas conversion on Cu-based catalysts, CO successive hydrogenation can also produce methanol [\[27,37,38,65,69\],](#page-11-0) by decreasing the formation barrier of $CH_x(x = 1-3)$ and/or increasing that of methanol, in this way, methanol formation can be suppressed, and more CH_x intermediates will be formed. The results show that methanol prefers to be formed in kinetics rather than the $CH_x(x = 1-3)$ intermediates on the RhCu $(1 1 1)$ and CH_x($x = 1,3$)/RhCu(1 1 1) surfaces, which exhibits better selectivity towards methanol formation. However, the dominant monomer CH₂ formation kinetically competes with methanol formation on $CH₂/RhCu(1 1 1)$ due to the close overall barriers of 174.8 and 174.8 kJ·mol⁻¹, the formed methanol quickly desorbs from the surface, namely, $CH₂/RhCu(1 1 1)$ surface significantly improves the selectivity towards $CH₂$ formation compared to the clean RhCu(1 1 1), CH/RhCu(1 1 1) and CH₃/RhCu(1 1 1) surfaces.

Previous researches about syngas conversion over the (1 1 1) [\[30,35\]](#page-11-0) and $(2 1 1)$ [\[35\]](#page-11-0) surfaces of Rh catalyst, as well as the (1 0 0) [\[38\],](#page-11-0) (1 1 0) [\[37\],](#page-11-0) (1 1 1) [\[65\]](#page-11-0) and (2 1 1) [\[27\]](#page-11-0) surfaces of Cu catalyst do not considered $CH_x(x = 1-3)$ intermediate itself as the co-adsorbed promoter, which showed that methanol formation was more preferred in kinetics over $CH_x(x = 1-3)$ formation. However, in this study, the surface adsorbed $CH_x(x = 1-3)$ intermediate itself is considered to act as a co-adsorbed promoter for the formation of CH_x intermediates over RhCu(111) surface, it presents a positive effect for the catalytic activity enhancement of CO activation to form $CH_x(x = 1-3)$ intermediate, especially, the dominant $CH₂$ intermediate acted as a co-adsorbed promoter exhibits excellent catalytic activity and selectivity towards itself formation, and effectively inhibit methanol formation, and therefore the abundant $CH₂$ sources are provided for the subsequent reactions of $C₂$ oxygenates formation.

3.3.2. The role of adsorbed CH_x($x = 1-3$) intermediate in the C₂ oxygenates formation

Under the conditions that the surface adsorbed CH_x intermediate itself is not considered as a co-adsorbed promoter, previous studies $[19]$ found that the reactions related to CH_x intermediates on the (1 1 1) and (5 5 3) surfaces of Rh catalyst mainly contribute to CH₄ formation instead of C_2 oxygenates. Moreover, Choi and Liu [\[30\]](#page-11-0), Kapur et al. [\[35\]](#page-11-0), Yang et al. [\[61\]](#page-11-0) also confirmed that CH₄ or C₂ hydrocarbons are the main products in syngas conversion on the $(1 1 1)$ and $(2 1 1)$ surfaces of Rh catalyst. Further, CH₄ formation is energetically competitive with C_2 oxygenates on the Rh-doped $Cu(1\ 1\ 1)$ [\[19\]](#page-11-0) and the Rh-doped $Cu(2\ 1\ 1)$ [\[71\]](#page-11-0) surfaces.

As presented in [Fig. 7](#page-7-0), on the clean RhCu(1 1 1) surface, C_2 oxygenates and methane are the dominant products due to the close overall barriers, which agree with that on the RhCu(1 1 1) and RhCu(2 1 1) surfaces [\[19,71\]](#page-11-0). However, on $CH_x(x = 1-3)/R$ hCu (1 1 1) surface, C_2 oxygenates CH₂CHO becomes to be the main product, indicating that the surface adsorbed $CH_x(x = 1-3)$ intermediate itself acted as a co-adsorbed promoter over RhCu(1 1 1) surface exhibits better selectivity towards C_2 oxygenates; meanwhile, the selectivity between $CH₂CHO$ and major by-products $(CH₄$ and $C₂H₄$) is quantitatively analyzed using the barrier difference between CH₂CHO and major by-products as a descriptor. The larger barrier difference means that $CH₂CHO$ has higher selectivity and the by-product has lower selectivity. Our results show that the barrier differences on the RhCu(111) and CH_x($x = 1-3$)/RhCu (1 1 1) surfaces correspond to the values of 3.5, 10.5, 21.6 and 30.4 kJ·mol⁻¹, respectively. Thus, CH₂CHO selectivity follows the order of $CH_3/RhCu(1 1 1) > CH_2/RhCu(1 1 1) > CH/RhCu(1 1 1)$ $>$ RhCu(1 1 1).

Among the four RhCu(1 1 1) surfaces studied, compared to the clean RhCu(1 1 1) surface $(31.9 \text{ kJ} \cdot \text{mol}^{-1})$, $CH_2/RhCu(1 1 1)$ or $CH₃/RhCu(1 1 1)$ surface with the surface adsorbed $CH₂$ or $CH₃$ intermediates acted as a co-adsorbed promoter exhibit a highly catalytic activity for $CH₂CHO$ formation due to the small barriers $(24.4 \text{ or } 5.6 \text{ kJ} \cdot \text{mol}^{-1})$, whereas CH intermediate has little effect on the catalytic activity $(34.6 \text{ kJ} \cdot \text{mol}^{-1})$. The activity of CH₂CHO formation follows the order of $CH₃/RhCu(1 1 1) > CH₂/RhCu$ $(1 1 1)$ > RhCu $(1 1 1)$ > CH/RhCu $(1 1 1)$.

On the basis of above analysis, the surface adsorbed $CH₂$ or $CH₃$ intermediates acted as a co-adsorbed promoter over RhCu(1 1 1) surface significantly enhances the catalytic activity and selectivity of C_2 oxygenates. Although CH_3 intermediate is more preferred over $CH₂$ intermediate, $CH₂$ intermediate itself as the dominant monomer should played a dominant role in promoting the formation of C_2 oxygenates.

In addition, as mentioned above, $CH₂/RhCu(1 1 1)$ surface significantly promote $CH₂$ formation compared to RhCu(111), CH/RhCu(1 1 1) and CH₃/RhCu(1 1 1) surfaces, moreover, CH₂ intermediate itself as the dominant monomer played a dominant role in promoting the formation of C_2 oxygenates by CHO insertion into $CH₂$. However, for the reactions of CHO insertion into CH₂ over $CH₂/RhCu(1 1 1)$ surface, it is noted that surface adsorbed $CH₂$ intermediates may react with the co-adsorbed promoter $CH₂$, correspondingly, CHO species will act as the co-adsorbed promoter over RhCu(1 1 1) surface, which is denoted as CHO/RhCu(1 1 1) surface, as shown in Fig. S13, the results show that the reactions of $CH₂$ coupling with $CH₂$ in the presence of CHO species over CHO/RhCu(1 1 1) surface is still difficult in kinetics than the reaction of CHO insertion into $CH₂$ in the presence of CH₂ species over $CH₂/RhCu(1 1 1)$ surface (71.8 vs. 24.4 kJ/mol). On the other hand, in the formation process of the favored $CH₂$ monomer via $CH₂O$ and $CH₂OH$ dissociation, OH species can be formed to affect the reactions of syngas conversion, thus, the effect of OH species acted as a co-adsorbed promoter on the key elementary reactions in syngas conversion to form C_2 oxygenates including $CO + H \rightarrow CHO$ for CO activation, $CH_2OH \rightarrow CH_2 + OH$ for CH_2 formation, CHO + CH₂ \rightarrow CH₂CHO for C₂ oxygenates formation, were further investigated. As shown in Fig. $S14$, compared to RhCu(111) surface, OH-species over RhCu(1 1 1) surface denoted as OH/RhCu (1 1 1) surface with OH-species acted as a co-adsorbed promoter can promote these three elementary reactions. However, compared to the $CH_x(x = 1-3)/RhCu(1 1 1)$ surface, the effect of OH/RhCu (1 1 1) surface on these elementary reactions is weaker, namely, the promotion effect of OH species acted as a co-adsorbed promoter is weaker than that of CH_x species acted as a co-adsorbed promoter over the RhCu(1 1 1) surface.

3.3.3. The analysis of electronic properties

Based on above results, once the dominant monomer $CH₂$ intermediate is produced over $CH_x(x = 1-3)/RhCu(1 1 1)$ surface, C_2 oxygenates preferred to be formed with high selectivity. Thus, CO activation and conversion to form the dominant $CH₂$ intermediate becomes a crucial step in syngas conversion to C_2 oxygenates. Aiming at further determining the microscopic reason why the surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter over RhCu(1 1 1) surface play a new and key role in CO activation to form the dominant monomer $CH₂$, the analysis of electronic properties is carried out to obtain the correlation between electronic properties and catalytic performance.

As shown in Fig. 8, the differential charge density of $RhCu(1 1 1)$ and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces showed that Cu loses electrons and Rh accepts electrons, which is in accordance with the results obtained by Rodriguez et al. [\[24\]](#page-11-0). Meanwhile, the Bader charge is calculated to quantitatively analyze the number of electrons accepted by Rh atom, the Bader charge of Rh atom are

Fig. 8. Differential charge density of Rh atom and its surrounding Cu atoms on the RhCu(1 1 1) and CH_x(x = 1-3)/RhCu(1 1 1) surfaces. The blue and yellow shaded regions represent the charge loss and charge gain, respectively. The values of absolute isosurface is 0.003 e \AA^{-3} .

Fig. 9. The relationship between the activity of CO activation to $CH_x(x = 1-3)$ and the surface d-band center or the Bader charge of Rh atom over the RhCu(1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces. The d-band center corresponds to the Rh atoms and its adjacent surface and subsurface Cu atoms over the RhCu(1 1 1) and $CH_x(x = 1-3)/RhCu(1 1 1)$ surfaces.

Fig. 10. (a) Gas phase CO DOS curves with respective electron isodensity surfaces representing each molecule orbital (MO), (b) MO, and (c) DOS of CO adsorbed at the most stable sites of the RhCu(1 1 1), CH/RhCu(1 1 1), CH₂/RhCu(1 1 1) and CH₃/RhCu(1 1 1) surfaces.

 -0.37 , -0.14 , -0.18 and -0.19 e on the RhCu(111), CH/RhCu (1 1 1), $CH₂/RhCu(1 1 1)$ and $CH₃/RhCu(1 1 1)$ surfaces, respectively; Namely, in comparison with the clean RhCu(1 1 1) surface, $CH_x(x = 1-3)/RhCu(1 1 1)$ surface with the surface adsorbed $CH_x(x = 1-3)$ intermediates decreases the number of electrons accepted by Rh atom, which weakens the adsorption ability of key CH_xO($x = 0-3$) and CH_xOH($x = 1,2$) intermediates. On the other hand, the d-electrons and/or empty d-orbitals of transition metals

[\[74–77\]](#page-11-0) are closely related to their catalytic activity, and the location of d-band center determines the adsorption strength of adsorbed species. As shown in the black line of [Fig. 9,](#page-8-0) the deviation degree of d-band center from the Fermi level are -2.42 , -2.55 , -2.54 and -2.46 eV on the RhCu(1 1 1) and CH_x(x = 1-3)/RhCu (1 1 1) surfaces, respectively, suggesting that the presence of surface adsorbed $CH_x(x = 1-3)$ intermediates makes the d-band center far from the Fermi level compared to the clean RhCu (1 1 1) surface, which also weakens the adsorption ability of key $CH_xO(x = 1-3)$ and $CH_xOH(x = 1,2)$ intermediates.

As mentioned above, the surface adsorbed $CH_x(x = 1-3)$ intermediates decreases the adsorption ability of $CH_xO(x = 1-3)$ and $CH_xOH(x = 1,2)$ intermediates, which originate from the lateral interaction between the key intermediates and the co-adsorbed CH_x intermediate as a promoter. As a result, the decreasing of adsorption ability promotes the migration of these key intermediates towards their more favorable active sites [\[64\],](#page-11-0) which is more favorable for the C -O bond cleavage of these key intermediates leading to the catalytic activity enhancement of $CH_x(x = 1-3)$ intermediates formation. The results obtained by the analysis of electronic properties agree with our kinetics results. In addition, Zha et al. [\[48\]](#page-11-0) showed that compared to the presence of H atoms, the presence of OH intermediate is favorable for decreasing the adsorption energy of reaction intermediates in the process of $CH_x($ $x = 1-3$) formation, and improves their migration ability among the surface active sites, thereby the presence of OH species promotes CO activation to form CH_x intermediates.

In order to further verify that the adsorption site that is after the migration of surface species is more favorable for CO activation to form CH_x intermediates, the projected density of states (pDOS) onto the C -O bond of CO were calculated to probe into the role of surface adsorbed $CH_x(x = 1-3)$ intermediates. The primary shifting of $2\pi^*$ bands is due to the electron donation from the d orbital of metal catalyst to the $2\pi^*$ orbital of CO [\[78\].](#page-11-0) We firstly consider the gas phase CO molecule, the C/O pDOS together with the electron density isosurfaces of the MOs and CO molecular orbital diagram are depicted in [Fig. 10\(](#page-9-0)a) and (b), respectively. The pDOS results of adsorbed CO (see Fig. $10(c)$) show that the electron population of $2\pi^*$ anti-bonding orbital for CO adsorbed on the CH/RhCu (1 1 1), $CH_2/RhCu(1 1 1)$ and $CH_3/RhCu(1 1 1)$ surfaces are 3.006, 3.014, and 3.008 e, respectively, which were higher than that $(2.950 e)$ on the clean RhCu $(1 1 1)$ surface. In other words, the more electron transfer from the d-orbital of metal catalyst to the adsorbed CO anti-bonding orbital means the more significant weakening of the C- σ bond [\[78,79\]](#page-11-0). Therefore, the adsorption site after CO migration is more favorable for the $C-O$ bond activation of CO, which further confirms our kinetics results.

In general, compared to the traditional understandings about the role of CH_x species as the reactive intermediate in syngas conversion to C_2 oxygenates, a new fundamental mechanism about the role of surface adsorbed CH_x intermediates is proposed in this study, that is, the surface adsorbed CH_x intermediate itself can act as a co-adsorbed promoter to self-promote CO activation and conversion to C_2 oxygenates with high catalytic activity and selectivity. This so-called CH_x self-promoting syngas conversion open a new mechanism that is likely general and involved in the reactions related to the formation of $CH_x(x = 1-3)$ intermediates.

4. Conclusions

This study employed density functional theory calculations to reveal the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter in self-promoting syngas conversion to form the CH_x intermediates and C_2 oxygenates over the Rh-doped Cu catalyst. The Rh-doped Cu catalyst is modeled using the clean RhCu(1 1 1) and $CH_v(x = 1-3)/RhCu(1 1 1)$ surfaces. The results show that methanol formation is more favorable than $CH_x(x =$ 1–3) intermediates on the clean RhCu(1 1 1) surface, however, the surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter over RhCu(1 1 1) surface not only significantly promote the formation of the dominant monomer $CH₂$, but also inhibit methanol formation. Especially, the dominant monomer $CH₂$ acted as a co-adsorbed promoter exhibits higher catalytic activity and selectivity towards its self-formation. Further, starting from the dominant monomer $CH₂$, CH₄ formation on the clean RhCu(1 1 1) surface is energetically competitive with C_2 oxygenates CH₂CHO; however, $CH_x(x = 1-3)/RhCu(1 1 1)$ surface exhibits higher selectivity towards $CH₂CHO$ by CHO reaction with $CH₂$ instead of the hydrocarbons, especially, CH₂/RhCu(111) and CH₃/RhCu(111) surfaces significantly enhance the activity and selectivity of C_2 oxygenates in comparison with the clean RhCu(1 1 1) and $CH₃/RhCu$ (1 1 1) surfaces. Taking the dominant monomer $CH₂$ and the C-C chain of C_2 oxygenates into account, compared to the clean RhCu $(1 1 1)$ surface, the surface adsorbed CH₂ intermediate as a coadsorbed promoter over RhCu(1 1 1) surface played a fundamental role in self-promoting syngas conversion to form C_2 oxygenates, which significantly improved the activity and selectivity of syngas conversion to form C_2 oxygenates, and inhibit the formation of methanol and hydrocarbons.

The analysis of electronic properties including the differential charge density, the Bader charge and the d-band center give out the microscopic reason why the surface adsorbed $CH_x(x = 1-3)$ intermediates as a co-adsorbed promoter over RhCu(1 1 1) surface play a key role in CO activation to form CH_x intermediate. The correlation between electronic properties and catalytic performance is obtained. A new mechanism for the new role of surface adsorbed $CH_x(x = 1-3)$ intermediates has been proposed, that is: the surface adsorbed $CH_x(x = 1-3)$ intermediate itself can acted as a coadsorbed promoter on RhCu(1 1 1) surface to promote the migration of key intermediates $CH_xO(x = 1-3)$ or $CH_xOH(x = 1,2)$ towards their more favorable active sites, which is more favorable for the C –O bond cleavage of these key intermediates; Thus, the catalytic activity of $CH_x(x = 1-3)$ formation in CO activation is enhanced.

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Appendix A. Supplementary material

The computational details and supplementary date, including the methods for calculating the relevant energy, the adsorption and co-adsorption behaviors of key intermediates, the reactions of CO activation to form CH_x intermediates, the reactions related to CH₂ species, the reactions related to CH_x species over the p (4×4) surfaces, Microkinetic modeling and the d-band analysis are all described in detail. Supplementary data to this article can be found online at <https://doi.org/10.1016/j.jcat.2019.07.019>.

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